

Docket No.: 2336-196

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

LEE, Byoung Hwa et al.

U.S. Patent Application No.: *not yet assigned*

Filed: *herewith*

For: MATCHING CIRCUIT AND LAMINATED DUPLEXER WITH THE MATCHING CIRCUIT

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

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INFORMATION DISCLOSURE CITATION IN AN APPLICATION  (PTO-1449)						ATTY. DOCKET NO. 2336-196		U.S. APPLICATION NO. Not yet assigned			
						APPLICANT LEE, Byoung Hwa et al.					
						FILING DATE herewith		GROUP			
U.S. PATENT DOCUMENTS											
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE					
FOREIGN PATENT DOCUMENTS											
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation					
						Yes	No				
	2002-164710	June 7, 2002	Japan			Abstract					
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)											
EXAMINER					DATE CONSIDERED						

**EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.